

L Number	Hits	Search Text	DB	Time stamp
1	2617	(((((wiring near (layer film)) with (hole plug)) and (gate and source and drain) and ((insulat\$3 dielectric) near (layer film))) and (substrate wafer))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/02 18:10
2	479	(((((wiring near (layer film)) with (hole plug)) and (gate and source and drain) and ((insulat\$3 dielectric) near (layer film))) and (substrate wafer)) ) and (dielectric near constant)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/02 18:10
3	1340	(((((wiring near (layer film)) with (hole plug)) and (gate and source and drain) and ((insulat\$3 dielectric) near (layer film))) and (substrate wafer)) ) and concentration	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/02 18:10